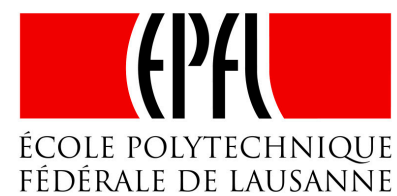




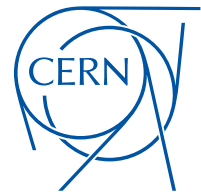
Work supported by the Swiss State  
Secretariat for Education, Research  
and Innovation SERI



# Electron cloud

L. Mether

I. Bellafont, G. Rumolo



FCC Week 2018, Amsterdam  
April 9<sup>th</sup>-13<sup>th</sup> 2018

Electron clouds can cause transverse instabilities, tune shift and spread, emittance growth, losses, heat load and vacuum degradation

- Effects can effectively be mitigated by preventing the build-up of electron clouds
- Need to identify required conditions to sufficiently suppress electron cloud build-up

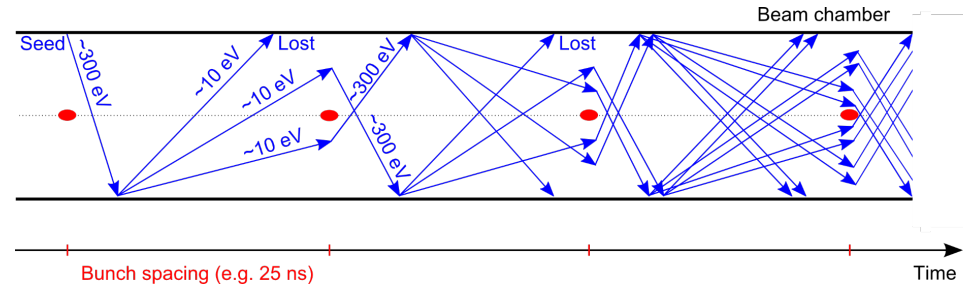
## Previous studies

E-cloud studies for 25 ns, 12.5 ns and 5 ns beams:

- Build-up in arc dipoles, quadrupoles, drifts
- Effect of photoelectrons
- Beam dynamics simulations to confirm instability thresholds

Studies performed using

- Main chamber of beam screen (2015 version)
- Cu surface



## New results

- Cloud distribution and beam screen geometry
- Bunch train pattern and other updated parameters
- Photoelectrons according to distribution from ray tracing

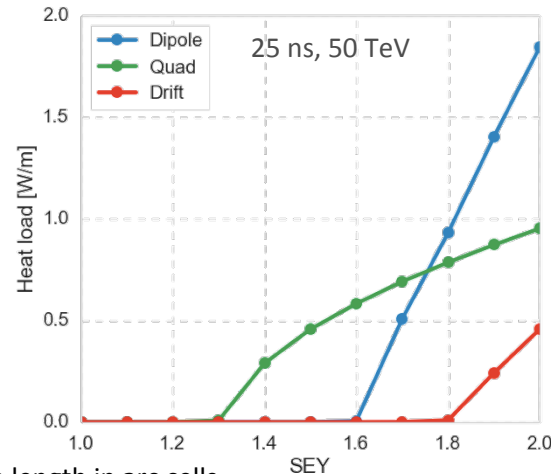
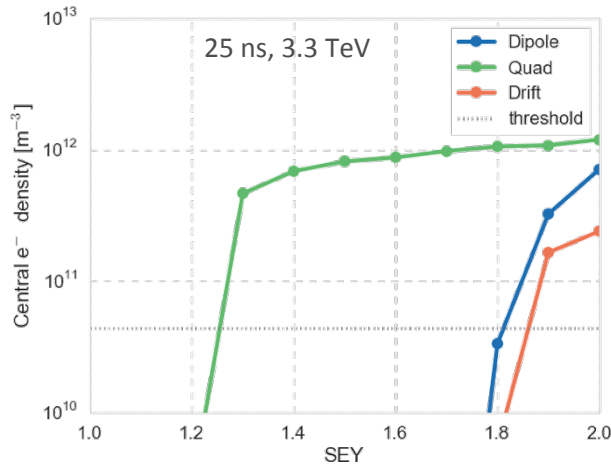
# Overview of previous results

## Results of build-up studies (no photoelectrons):

- Multipacting **thresholds for the 25 ns beam are moderate**, and build-up can be efficiently suppressed with coatings
- Tighter constraints **for alternative bunch spacings**, especially 12.5 ns → maximum **SEY no larger than 1 may be needed for full suppression**

## Multipacting thresholds for build-up (Highest SEY without build-up)

	25 ns		12.5 ns		5 ns	
E [TeV]	3.3	50	3.3	50	3.3	50
Dipole	1.6	1.6	1.2	1.2	1.5	1.4
Quad	1.2	1.3	1.0	1.1	1.1	1.1
Drift	1.8	1.8	1.2	1.2	1.5	1.4



Scaled to device length in arc cells

## Main conclusions:

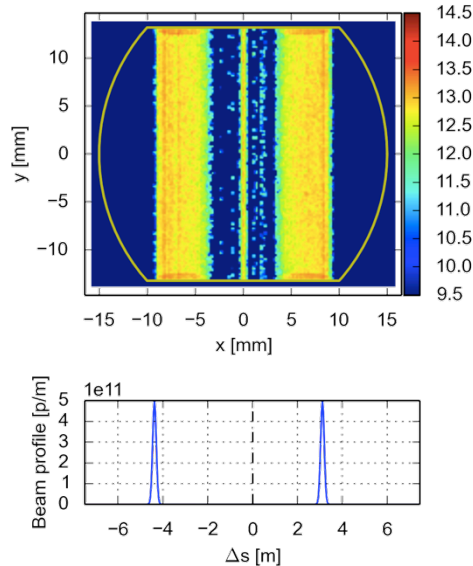
- **Heat loads with 25 ns are moderate** compared to the synchrotron radiation  $\sim 28.4$  W/m
- **Stability is critical**: central densities are above the instability threshold in most cases if build-up occurs, in particular in the quadrupoles and for the smaller bunch spacings

# Cloud distribution

The cloud distributions have been identified in order to determine where beam screen coating is required

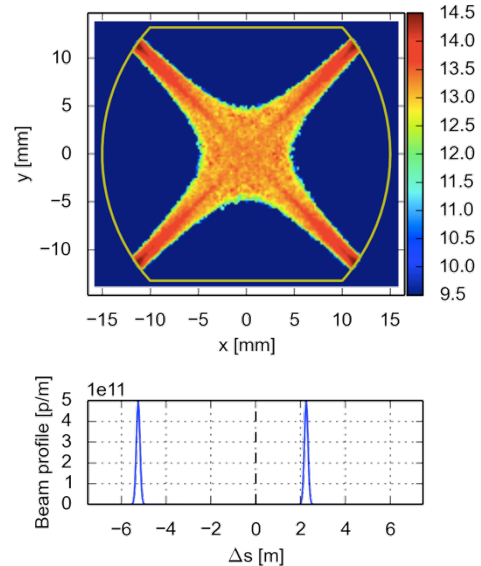
## Dipole

The coating should cover the **full top and bottom** of the chamber



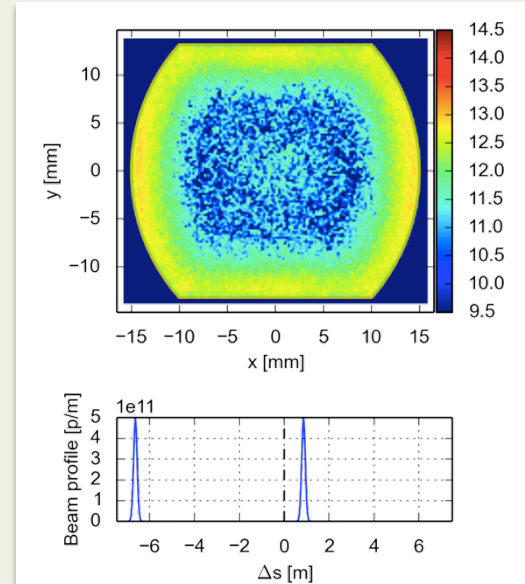
## Quadrupole

Coating is required **at 45°** to the horizontal plane



## Drift

Multipacting on all sides, hot spots along horizontal and vertical axes



# Effect of beam screen design

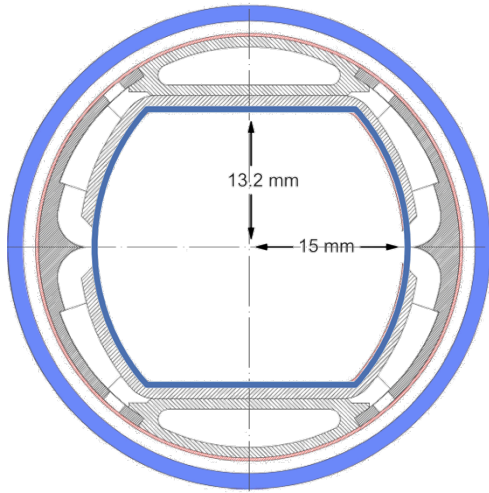
Evolution of beam screen design:

2015 → 2017

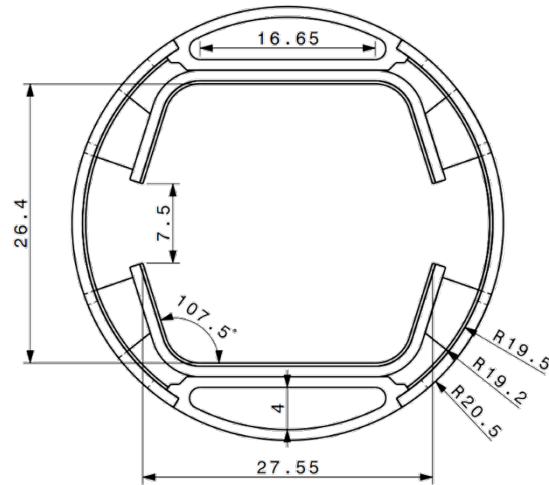
- Larger slit, saw-tooth surface, straight edges
- Impact expected mainly in the drifts, due to the cloud distribution in magnetic fields

2017 → 2018

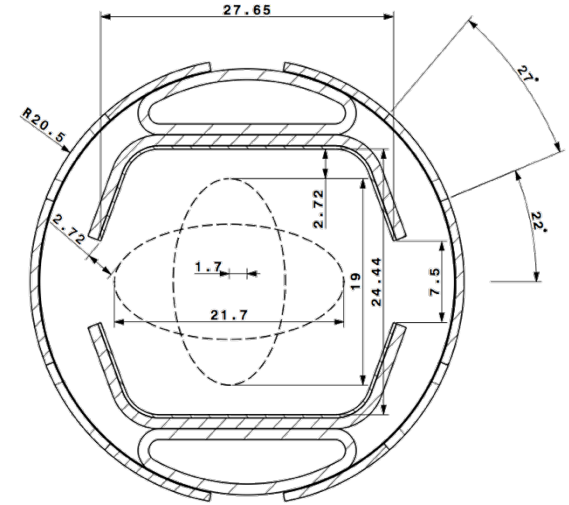
- Smaller vertical aperture (by 2 mm)
- Could impact results also in dipoles and quads



2015



2017



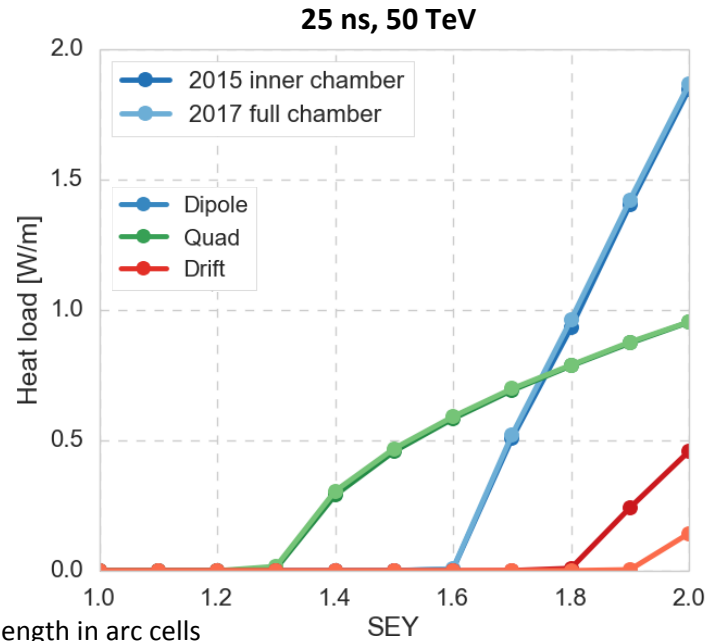
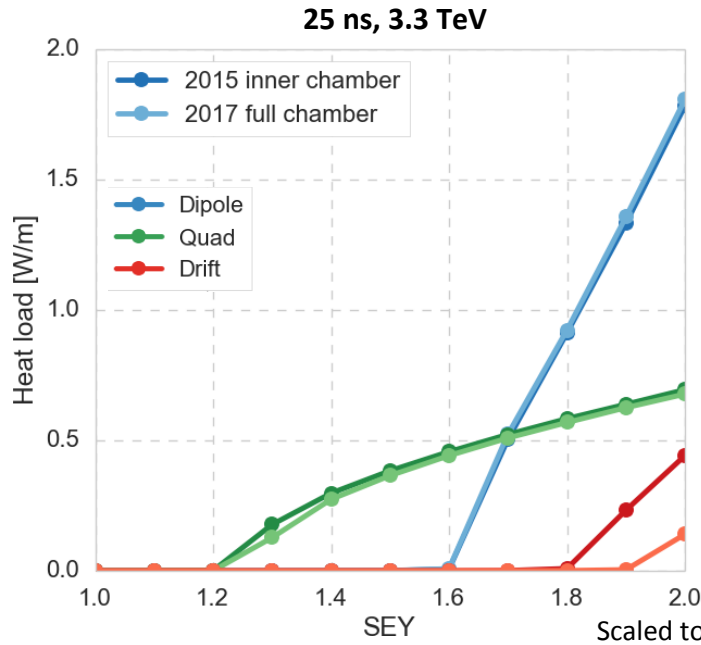
2018

C. Garion, J. Fernandez Topham et al, see talk of F. Perez

# Effect of beam screen design

2015 → 2017

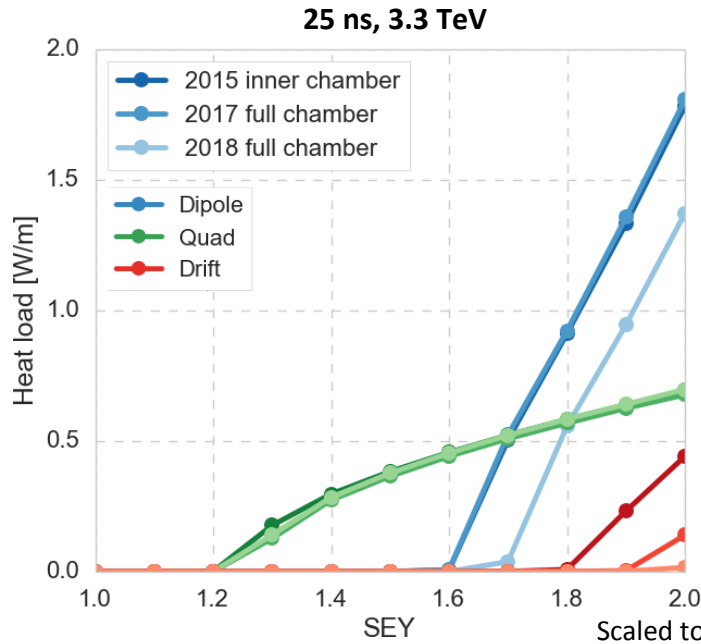
The **threshold in the drift is pushed higher**,  
no other significant effect



# Effect of beam screen design

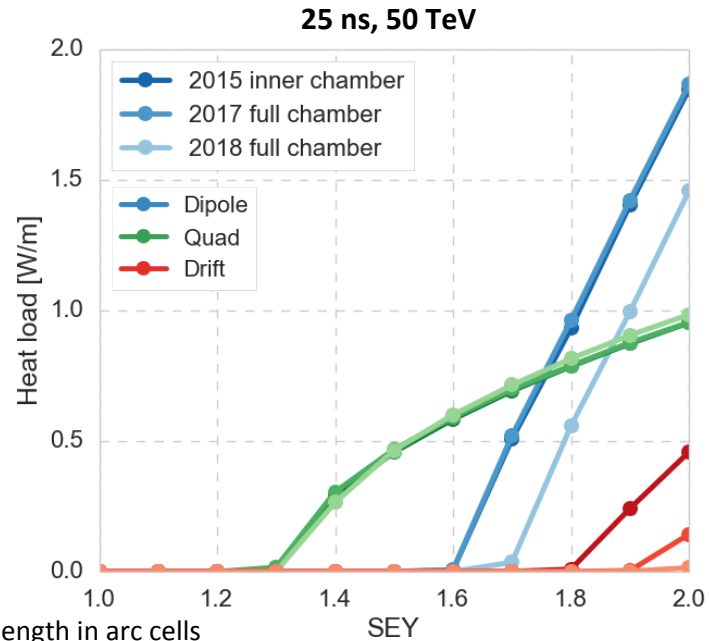
2015 → 2017

The **threshold in the drift is pushed higher**,  
no other significant effect



2017 → 2018

The drift threshold is increased further, and the  
**dipole threshold is slightly increased as well**



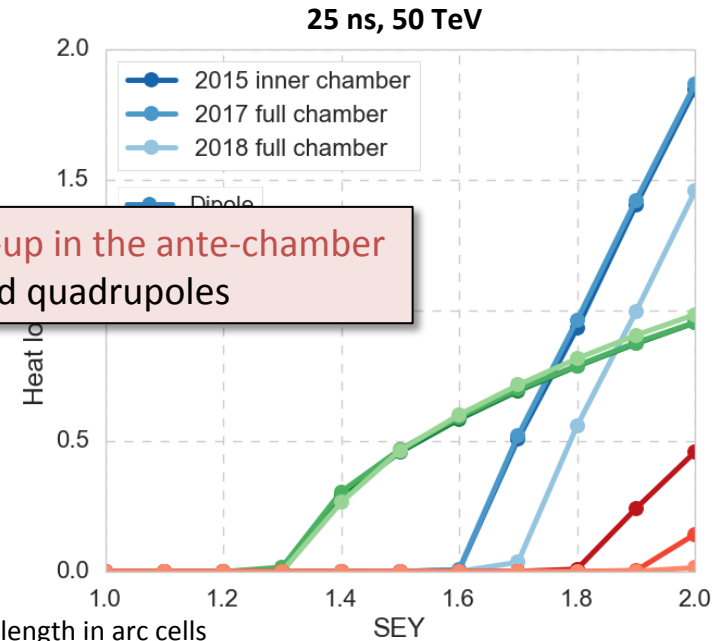
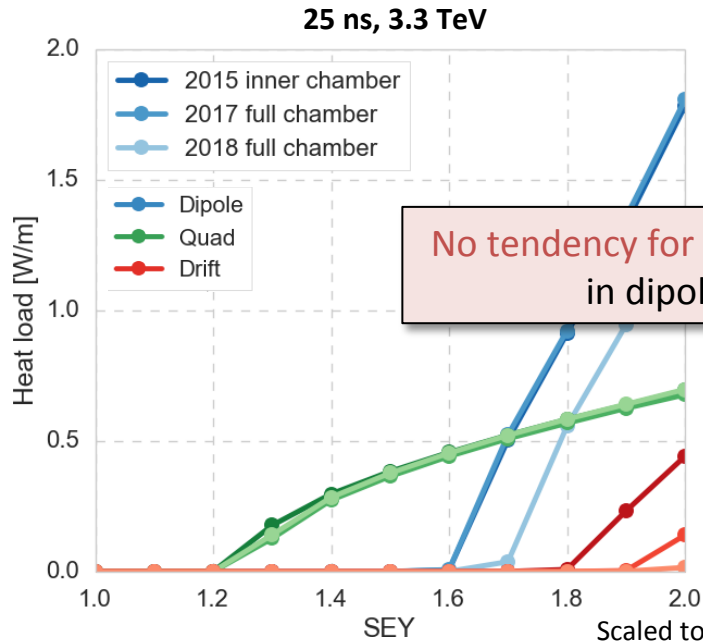
# Effect of beam screen design

2015 → 2017

The **threshold in the drift is pushed higher**,  
no other significant effect

2017 → 2018

The drift threshold is increased further, and the  
**dipole threshold is slightly increased as well**



No tendency for build-up in the ante-chamber  
in dipoles and quadrupoles



# Updated parameters

- **Bunch train pattern** defined by injection considerations  
Previously used 50 bunches + 12 empty slots for the 25 ns beam → **80 bunches + 17 empty slots**
- Arc element lengths
- Magnet strengths

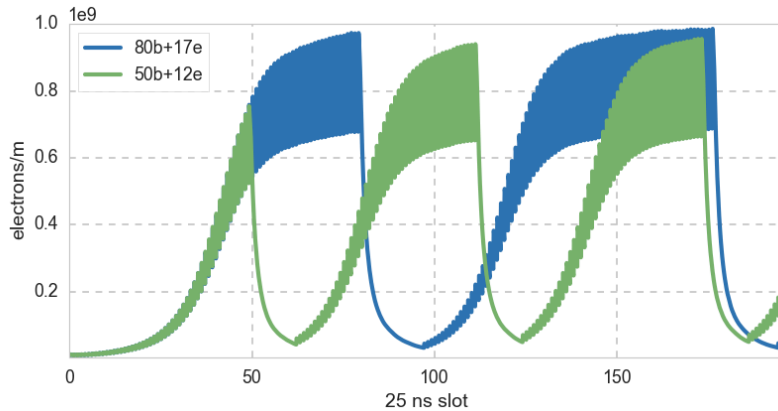
Simulation parameters in 2018			
Bunch spacing [ns]	25	12.5	5
Bunch intensity [ $p^+$ ]	$10 \times 10^{10}$	$5 \times 10^{10}$	$2 \times 10^{10}$
Norm. emittance [m]	2.2e-6	1.1e-6	0.44e-6
Bunch length [m]	0.08		
Bunch train pattern	<b>80b + 17e</b>	<b>160b + 34e</b>	<b>400b + 85e</b>
Arc elements	<b>Dipole: 16 T, 78.4 % of arc length</b>		
	<b>Quadrupole: 380 T/m, 6.4 % of arc length</b> 9.7 % of arc length with multipoles		
	<b>Drift: 10.7 % of arc length</b>		

# Updated parameters

- **Bunch train pattern** defined by injection considerations

Previously used 50 bunches + 12 empty slots for the 25 ns beam → **80 bunches + 17 empty slots**

- Arc element lengths
- Magnet strengths



The increase in train length has a stronger effect than the increase in gap length  
 → generally lower multipacting thresholds

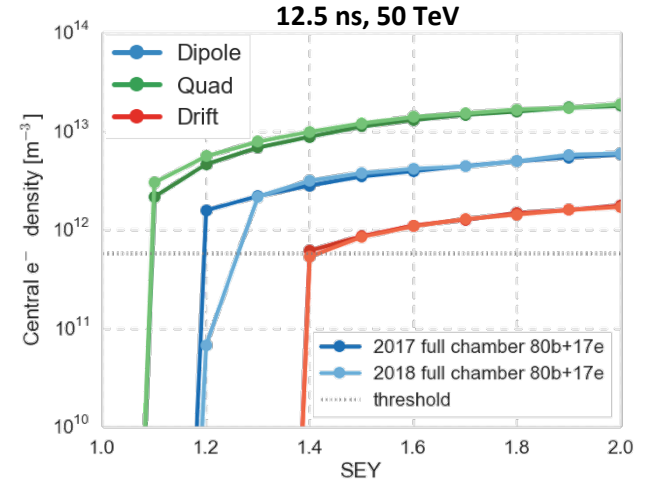
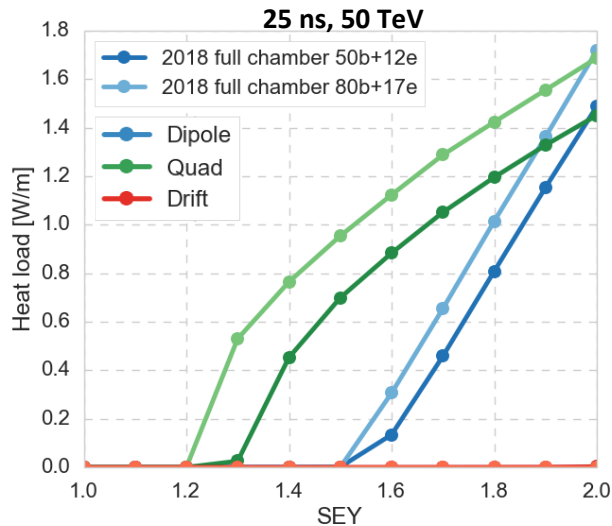
## Simulation parameters in 2018

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	<b>Quadrupole: 380 T/m, 6.4 % of arc length</b> 9.7 % of arc length with multipoles		
	<b>Drift: 10.7 % of arc length</b>		

# Updated parameters

- Lower multipacting thresholds in the dipoles and quadrupoles
- For the alternative bunch spacings the lower thresholds are particularly constraining:

Central densities are above the instability threshold even for low SEY above the threshold → full suppression needed for beam stability



**Multipacting thresholds with 2017 / 2018 chamber**  
(highest max SEY without build-up)

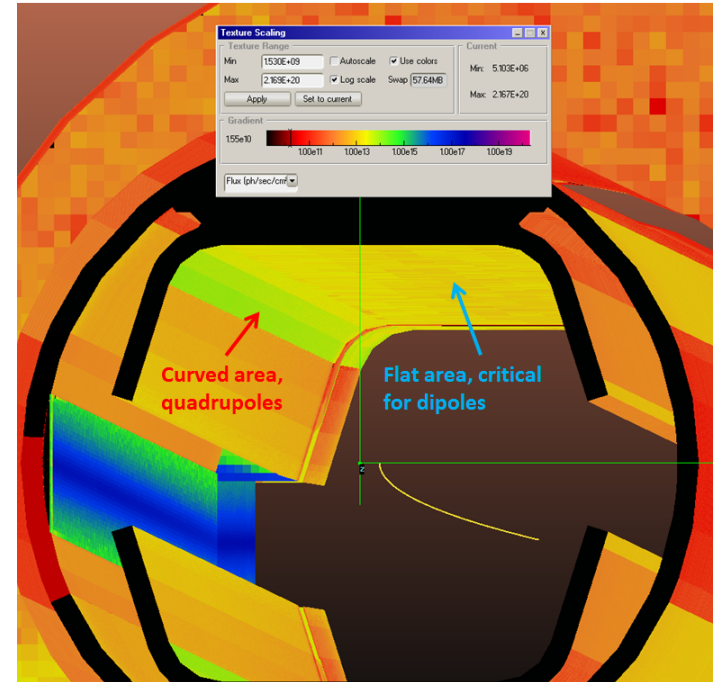
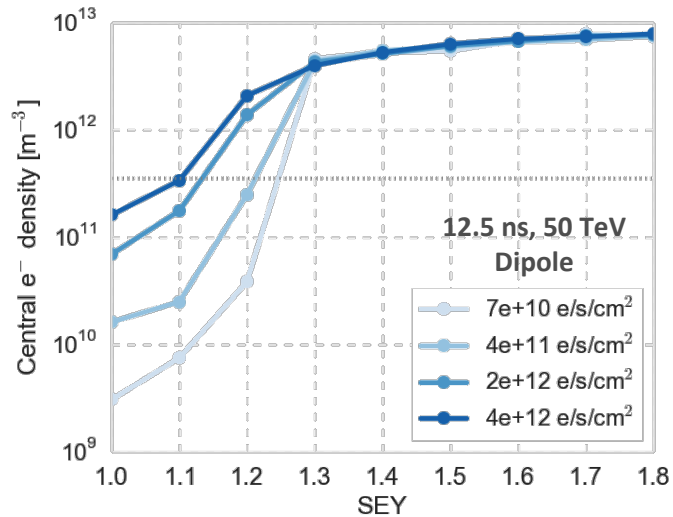
	25 ns		12.5 ns		5 ns	
E [TeV]	3.3	50	3.3	50	3.3	50
Dipole	1.4 / 1.5	1.4 / 1.5	1.1	1.1	1.5	1.5
Quad	1.2 / 1.1	1.2	1.0	1.0	1.1	1.0
Drift	2.0	2.0	1.3	1.3	1.6	1.6

# Photoelectrons

Previous studies showed that photoelectrons could raise the central density above the instability threshold also below the multipacting threshold, especially for the 12.5 and 5 ns beams

- Constraints on the photoelectron flux were estimated and considered by the beam screen design team, which found the 2017 model with saw-tooth compatible in dipoles and quadrupoles

I. Bellafont



# Photoelectrons

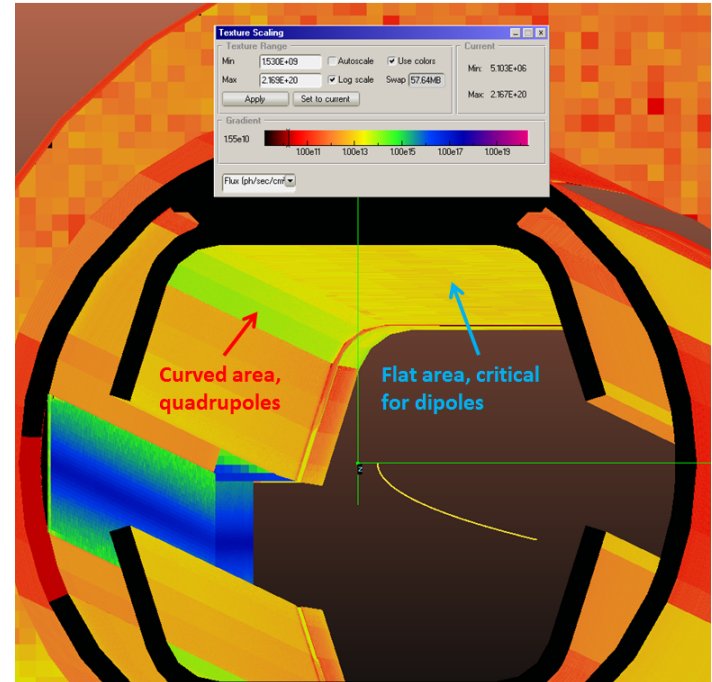
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I. Bellafont

Photoelectron flux **distributions based on ray-tracing studies implemented in the build-up simulations:**

- Conservative estimate (10% photoyield, 0% reflection): photoelectron flux  $5 \times 10^{10} - 5 \times 10^{11}$  e/cm<sup>2</sup>/s on inner surfaces
- LASE estimate: photoelectron flux  $10^9 - 10^{10}$  e/cm<sup>2</sup>/s on inner surfaces



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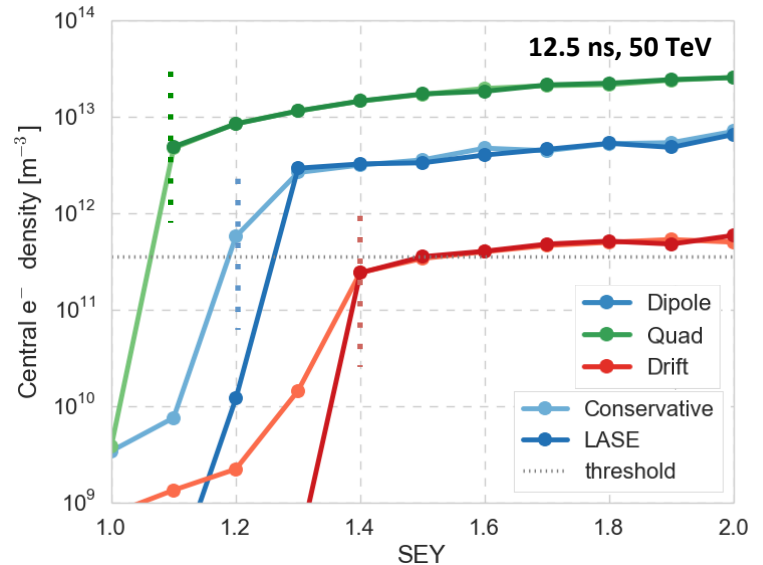
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- LASE estimate : photoelectron flux  $10^9 - 10^{10}$  e/cm<sup>2</sup>/s on inner surfaces

Simulations confirm that both cases are viable

- Central electron densities remain below the instability threshold for all bunch spacings when the SEY is below the multipacting threshold



# Photoelectrons

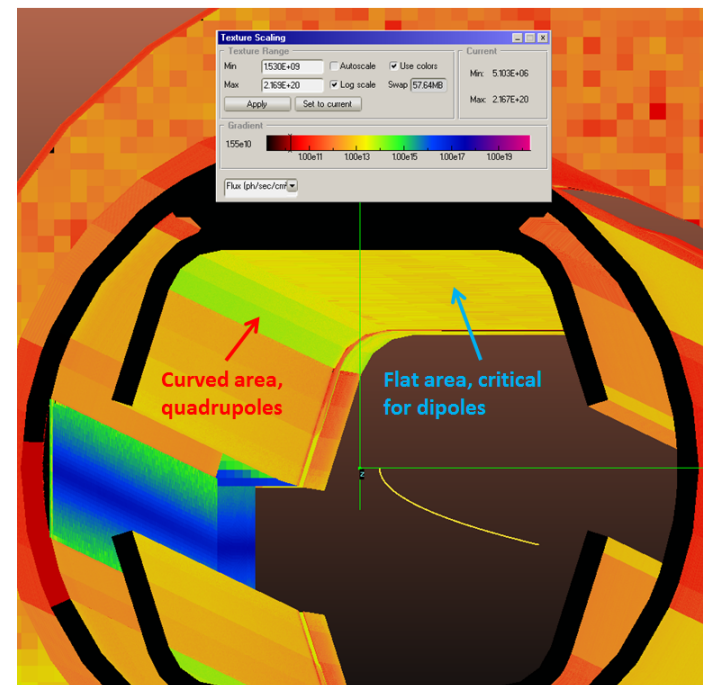
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I. Bellafont

Photoelectron flux distributions based on ray-tracing studies implemented in the build-up simulations:

- Scanned flux on saw-tooth area in range  $10^{12} - 10^{13}$  e/cm<sup>2</sup>/s



Previous studies showed that photoelectrons could raise the central density above the instability threshold also below the multipacting threshold, especially for the 12.5 and 5 ns beams

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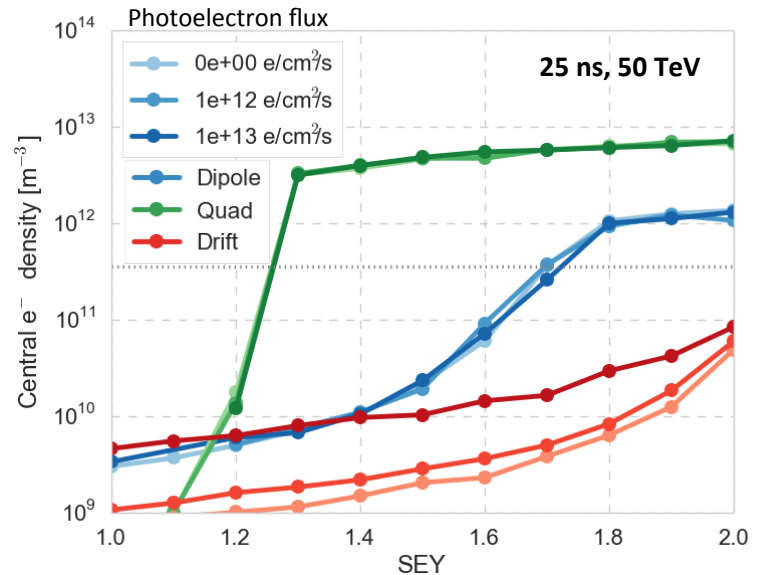
Photoelectron flux distributions based on ray-tracing studies implemented in the build-up simulations:

- Scanned flux on saw-tooth area in range  $10^{12} - 10^{13}$  e/cm<sup>2</sup>/s

The flux in the saw-tooth area affects the build-up mainly in field-free regions

- For the considered fluxes, central densities remain below the instability threshold for all bunch spacings when the SEY is below the multipacting threshold

Maximum expected flux in the saw-tooth area to be confirmed with beam screen design team





# Conclusion

The effect of beam screen geometry on e-cloud build-up evaluated

- The **large slit increases multipacting threshold in drifts**
- No significant difference between 2017 and 2018 geometries

Conditions to suppress build-up defined with full chamber and updated parameters

- An **amorphous carbon coating or LASE surface** should be **sufficient to suppress build-up for the 25 ns beam**
  - Coating required in dipoles and quadrupoles, should not be necessary in drifts unless significant photoelectron production occurs at the saw-tooth surface
- **For the alternative beams**, the situation is somewhat tighter than before
  - Full suppression needed for **stability** → **SEY ~1 in quadrupoles**
  - **Coating may be necessary also in field free regions**

Photoelectrons initialized according to ray-tracing simulations

- **Estimated photoelectron fluxes** are **within stability limits**
- Photoelectrons from saw-tooth increases density in drifts → expected flux to be confirmed with WP4

Spares

# Single bunch instability

Analytical estimate of **threshold electron density** for instability

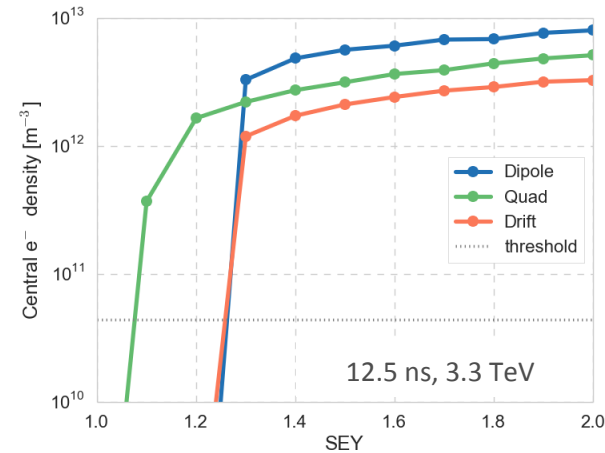
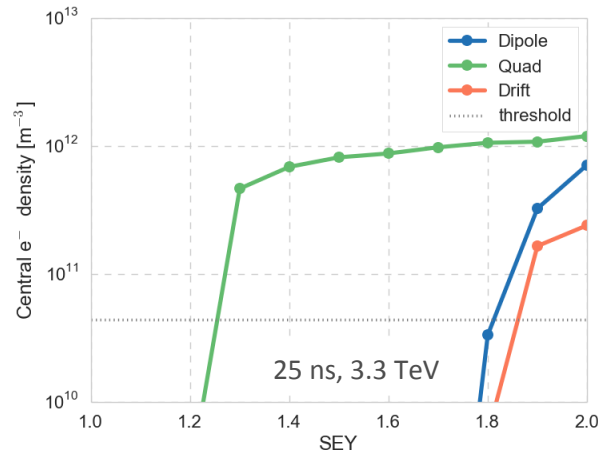
$$\rho_{e,th} = \frac{2\gamma\nu_s\omega_e\sigma_z/c}{\sqrt{3}KQr_0\beta L} \quad \text{with} \quad \omega_e = \sqrt{\frac{\lambda_p r_e c^2}{\sigma_y(\sigma_x + \sigma_y)}}, \quad K = \omega_e\sigma_z/c$$

$$Q = \min(\omega_e\sigma_z/c, 7)$$

With updated machine parameters

3.3 TeV	50 TeV
$6 \times 10^{10} \text{ m}^{-3}$	$3.6 \times 10^{11} \text{ m}^{-3}$

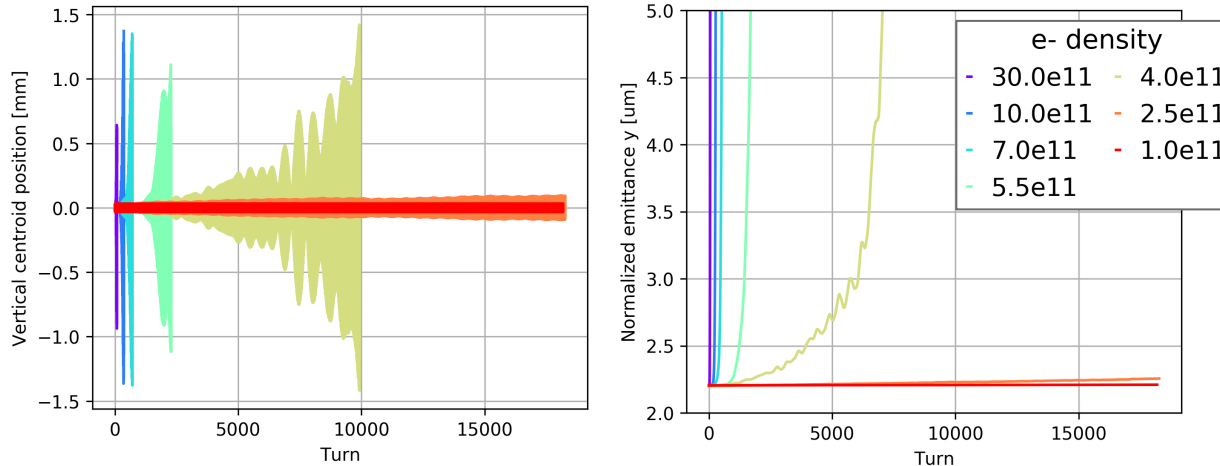
Above the multipacting threshold, central electron densities are in the instability regime



Central electron densities scaled to device length in half-cell

# Single bunch instability simulations

First instability simulation study: 25 ns beam at 3.3 TeV in dipole field – no stabilizing mechanisms



Ongoing studies:

- 5 ns at 3.3 TeV
- 25 ns at 50 TeV

→ seem to suggest similar scaling w.r.t. analytic estimate (TBC)

Over 17 000 turns ( $\sim 5$  s): instability threshold around  $1\text{-}2.5 \times 10^{11} \text{ m}^{-3}$

- Compare to analytic estimate scaled to dipole length:  $7.5 \times 10^{10} \text{ m}^{-3}$

→ Analytic estimate slightly pessimistic, by factor 2-3

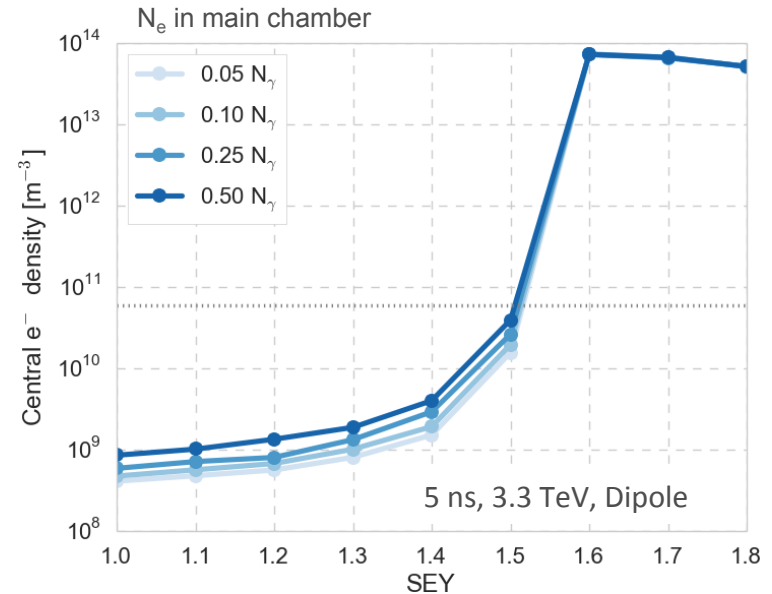
# Stability at injection

Electron densities at 3.3 TeV much below instability threshold

- Due to smaller number of photons, and critical energy below Cu work function

	FCC	FCC Injection		
E [TeV]	50	1.5	3.3	5.5
$E_c$ [eV]	4030	0.11	1.14	5.26
$N_\gamma/p^+m$	0.0497	0.00149	0.00328	0.00546
$N_{\text{eff}}/N_{\text{tot}}$	0.878	6.1e-20	2.5e-3	0.108
$N_{\text{eff}}/p^+m$	0.0436	9.1e-23	8.2e-6	5.9e-3

Most critical case for stability may be at some intermediate energy



# SEY model

SEY model based on extensive studies using laboratory measurements on the copper surface of the LHC beam chambers

$$\delta(E) = \delta_{\text{elas}}(E) + \delta_{\text{true}}(E)$$

$$\delta_{\text{elas}}(E) = R_0 \left( \frac{\sqrt{E} - \sqrt{E + E_0}}{\sqrt{E} + \sqrt{E + E_0}} \right)^2$$

$$R_0 = 0.7$$

$$E_0 = 150 \text{ eV}$$

$$\delta_{\text{true}}(E) = \delta_{\text{max}} \frac{E^s}{E_{\text{max}}^s - 1 + \left( \frac{E}{E_{\text{max}}} \right)^s}$$

$$E_{\text{max}} = 332 \text{ eV}$$

$$s = 1.35$$

$$E_{\text{max}}(\theta) = E_{\text{max}}(\theta = 0) (1 - 0.7 (1 - \cos \theta))$$

$$\delta_{\text{max}}(\theta) = \delta_{\text{max}}(\theta = 0) e^{\frac{(1 - \cos \theta)}{2}}$$

New measurements ongoing, with detailed data also at low energies

- Comparison of simulation results with standard LHC model and measured curves
- V. Petit: <https://indico.cern.ch/event/685341/>
- L.Bitikokos: <https://indico.cern.ch/event/714948/>

